

Notice of References Cited	Application/Control No. 09/489,356		Applicant(s)/Patent Under Reexamination SHIH ET AL.	
	Examiner Rudy Zervigon		Art Unit 1763	Page 1 of 1

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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	B	US-			
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	D	US-			
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	J	US-			
	K	US-			
	L	US-			
	M	US-			

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	N	63-203098	08-1998	Japan	Kizawa, Seiichi	H04R 31/00
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NON-PATENT DOCUMENTS

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	U	J. Linke et al. Behavior of Boron Doped Graphites, Plasma Sprayed Boron Carbides and a-C/B:H as Plasma Facing Material, J. Fusion Tech. V.20, pp. 228-231, Sep. 1991.
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.